

## Electronic Patent Application Fee Transmittal

<b>Application Number:</b>	10666331			
<b>Filing Date:</b>	17-Sep-2003			
<b>Title of Invention:</b>	Methods for cleaning a set of structures comprising yttrium oxide in a plasma processing system			
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<b>Filer:</b>	Joseph A. Nguyen/Cassandra Reynolds			
<b>Attorney Docket Number:</b>	P1130/LMRX-P023			
Filed as Large Entity				
<b>Utility Filing Fees</b>				
<b>Description</b>	<b>Fee Code</b>	<b>Quantity</b>	<b>Amount</b>	<b>Sub-Total in USD(\$)</b>
<b>Basic Filing:</b>				
<b>Pages:</b>				
<b>Claims:</b>				
<b>Miscellaneous-Filing:</b>				
<b>Petition:</b>				
<b>Patent-Appeals-and-Interference:</b>				
Post-Allowance-and-Post-Issuance:				
<b>Extension-of-Time:</b>				
Extension - 1 month with \$0 paid	1251	1	120	120

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	1801	1	810	810
Total in USD (\$)				930